

L Number	Hits	Search Text	DB	Time stamp
1	0	("29/382").CCLS.	USPAT; EPO; JPO; DERWENT	2001/06/18 12:11
2	542	("427/259").CCLS.	USPAT; EPO; JPO; DERWENT	2001/06/18 12:11
3	463	("427/272").CCLS.	USPAT; EPO; JPO; DERWENT	2001/06/18 12:12
4	158733	29/\$.ccls.	USPAT; EPO; JPO; DERWENT	2001/06/18 12:12
5	159597	((("427/259").CCLS.) or (("427/272").CCLS.) or 29/\$.ccls.	USPAT; EPO; JPO; DERWENT	2001/06/18 12:12
6	4066	((("427/259").CCLS.) or (("427/272").CCLS.) or 29/\$.ccls.) and mask	USPAT; EPO; JPO; DERWENT	2001/06/18 12:12
7	310456	conform\$5	USPAT; EPO; JPO; DERWENT	2001/06/18 12:12
8	483	((("427/259").CCLS.) or (("427/272").CCLS.) or 29/\$.ccls.) and mask) and conform\$5	USPAT; EPO; JPO; DERWENT	2001/06/18 12:13
9	46086	electroplat\$3	USPAT; EPO; JPO; DERWENT	2001/06/18 12:13
10	161604	electrolytic\$3	USPAT; EPO; JPO; DERWENT	2001/06/18 12:13
11	4965	electrolytic\$3 same deposit	USPAT; EPO; JPO; DERWENT	2001/06/18 12:13
12	2032	electrolytic\$3 same depositing	USPAT; EPO; JPO; DERWENT	2001/06/18 12:13
13	6312	electrolytic\$3 same deposited	USPAT; EPO; JPO; DERWENT	2001/06/18 12:13
14	10712	(electrolytic\$3 same deposit) or (electrolytic\$3 same depositing) or (electrolytic\$3 same deposited)	USPAT; EPO; JPO; DERWENT	2001/06/18 12:13
15	54805	((electrolytic\$3 same deposit) or (electrolytic\$3 same depositing) or (electrolytic\$3 same deposited)) or electroplat\$3	USPAT; EPO; JPO; DERWENT	2001/06/18 12:13
16	119	((electrolytic\$3 same deposit) or (electrolytic\$3 same depositing) or (electrolytic\$3 same deposited)) or electroplat\$3) and (((("427/259").CCLS.) or ("427/272").CCLS.) or 29/\$.ccls.) and mask) and conform\$5)	USPAT; EPO; JPO; DERWENT	2001/06/18 12:14
17	338646	etch\$3	USPAT; EPO; JPO; DERWENT	2001/06/18 12:14
18	107	((((electrolytic\$3 same deposit) or (electrolytic\$3 same depositing) or (electrolytic\$3 same deposited)) or electroplat\$3) and (((("427/259").CCLS.) or ("427/272").CCLS.) or 29/\$.ccls.) and mask) and conform\$5)) and etch\$3	USPAT; EPO; JPO; DERWENT	2001/06/18 12:14
19	1058803	relief or pattern	USPAT; EPO; JPO; DERWENT	2001/06/18 12:15

L Number	Hits	Search Text	DB	Time stamp
18	107	(((((electrolytic\$3 same deposit) or (electrolytic\$3 same depositing) or (electrolytic\$3 same deposited)) or electroplat\$3) and (((("427/259").CCLS.) or ("427/272").CCLS.) or 29/\$.ccls.) and mask) and conform\$5)) and etch\$3	USPAT; EPO; JPO; DERWENT	2001/06/18 12:14
19	1058803	relief or pattern	USPAT; EPO; JPO; DERWENT	2001/06/18 12:15
20	87	(((((electrolytic\$3 same deposit) or (electrolytic\$3 same depositing) or (electrolytic\$3 same deposited)) or electroplat\$3) and (((("427/259").CCLS.) or ("427/272").CCLS.) or 29/\$.ccls.) and mask) and conform\$5)) and etch\$3) and (relief or pattern)	USPAT; EPO; JPO; DERWENT	2001/06/18 12:52
21	2	("4921583").PN.	USPAT; EPO; JPO; DERWENT	2001/06/18 12:53
22	31926	205/\$.ccls.	USPAT; EPO; JPO; DERWENT	2001/06/18 12:53
23	475	((electrolytic\$3 same deposit) or (electrolytic\$3 same depositing) or (electrolytic\$3 same deposited)) and 205/\$.ccls. and (relief or pattern)	USPAT; EPO; JPO; DERWENT	2001/06/18 12:53
24	8	((electrolytic\$3 same deposit) or (electrolytic\$3 same depositing) or (electrolytic\$3 same deposited)) or electroplat\$3) and 205/\$.ccls. and (relief or pattern) and (((("427/259").CCLS.) or ("427/272").CCLS.) or 29/\$.ccls.) and mask) and conform\$5)	USPAT; EPO; JPO; DERWENT	2001/06/18 12:54

20	87	(((electrolytic\$3 same deposit) or (electrolytic\$3 same depositing) or (electrolytic\$3 same deposited)) or electroplat\$3) and (((("427/259").CCLS.) or ("427/272").CCLS.) or 29/\$.ccls.) and mask) and conform\$5)) and etch\$3) and (relief or pattern)	USPAT; EPO; JPO; DERWENT	2001/06/18 12:15
----	----	---	--------------------------------	---------------------